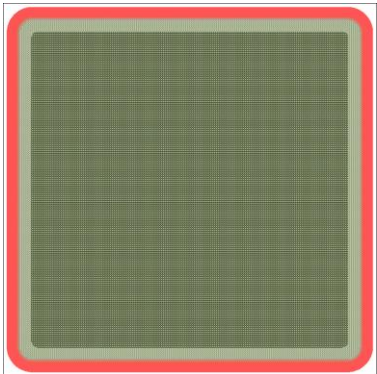


SiC Silicon-Carbide

1200V 20A Schottky Diode

Bonding Pad Information		Chip Information	
		Die Size (With Scribe Line)	3,180μm x 3,180μm
		Anode Pad Size	2,630μm x 2,630μm
		Scribe Line Size	100μm
		Wafer Size	4inches
		Wafer Thickness	160μm
		Gross Die	621ea
		Metallization	Front Side: Al/Cu : 4.0μm Back Side: Ti/Ni/Ag : 2.0μm

Maximum Ratings (T_c=25°C unless otherwise noted)

Parameter	Symbol	Value	Unit
Repetitive Peak Reverse Voltage	V _{RRM}	1200	V
Surge Peak Reverse Voltage	V _{RSM}	1200	V
DC Current	I _F	20	A
Operating Junction and Storage Temperature Range	T _J	-55 to 175	°C

Electrical Characteristics (T_A=25°C unless otherwise noted)

Parameter	Symbol	Conditions	Min.	Typ.	Max.	Unit
DC Blocking Voltage	V _R	I _R =100uA	1200	-	-	V
Forward Voltage	V _F	I _F =10A, T _J =25°C	-	1.2	1.5	V
		I _F =10A, T _J =175°C	-	1.4	-	
		I _F =20A, T _J =25°C	-	1.4	1.7	
		I _F =20A, T _J =175°C	-	1.9	-	
Reverse Current	I _R	V _R =1200V, T _J =25°C	-	3	50	μA
		V _R =1200V, T _J =175°C	-	50	600	
Total Capacitive Charge	Q _C	V _R =800V, T _J =25°C $Q_C = \int_0^{V_F} C(V) dV$	-	92	-	nC
Total Capacitance	C _j	V _R =800V, f=1MHz	-	73	-	pF

NOTE:

- I_F evaluated by TO247-2L package type.
- The data tested by pulsed, pulse with ≤ 300us, duty cycle ≤ 2%.